# **Product Samples**

## **ATP1008: Plated Gold Bumps**

Applied Thin-Film Products (ATP) is pleased to provide ceramic thin-film samples for your evaluation.

TaN/TiW/Au metalization with plated Gold Bumps on Aluminum Oxide( $Al_2O_3$ ). Gold Bumps are used to eliminate wire bonding, which will improve electrical performance at higher frequencies. This is done by eliminating long bond wires and flipping the chip onto the Gold contact bumps.

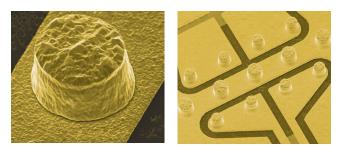
#### **Material Specifications**

#### Asfired High Density 996 Aluminum Oxide Superstrate 996

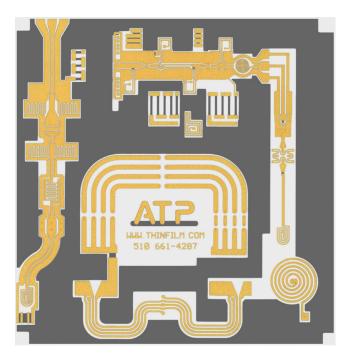
Properties	Values
Chemical Composition	Al <sub>2</sub> O <sub>3</sub>
Purity	99.6%
Color	White
Nominal Density	3.88g/cm³
Surface Finish (Asfired)	3µ''(76.2nm)
Camber	0.002'' (0.0508mm)
Thickness	0.015'' (0.381mm)*
Thickness Tolerance (±)	0.001'' (0.0254mm)
Coefficient of Thermal Expansion (CTE)	7.0−8.3 x 10 <sup>-6</sup> (25−1000°C)
Thermal Conductivity 100°C	26.9 Watts/m°K
Dielectric Constant 1 MHz	9.9 @ 1 MHz ±0.1
Dielectric Constant 10 GHz	9.7 @ 10 GHz ±0.1
Dissipation Factor (Loss Tangent)	0.0001 @ 1 MHz
Hardness (Rockwell)	87
Flexural Strength	90K (10 <sup>-3</sup> ) lbs/in² (620Mpa)
Compressive Strength	54 x 10 <sup>-3</sup> M lbs/in <sup>2</sup>
Grain Size	< 1.0µm

Material specifications provided by Coors Ceramic Company

ATP offers build-to-print service for a wide range of materials and metalization schemes. ATP fabricates circuits on substrates from As-Fired Alumina to Beryllium Oxide to Fused Silica, even Silicon. Metalizations range from the standard Tan/TiW/Au to films including Nickel, Palladium, or Titanium. ATP1008: Material is 15 mil As-Fired  $Al_2O_3$ TiW = 400-800 Ångströms Au = 120µ'' minimum Bump Height = 24 microns ±6 microns



### **Sample Provided**



At ATP, we constantly evolve our processing and material capabilities to reflect our customer's changing needs. If you have a circuit requirement that is out of the "normal" thin-film type, please contact ATP at 1.510.661.4287 or visit our website at www.thinfilm.com. ATP would enjoy discussing your application with you and working to develop a solution.

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